

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant	:	Washio et al.
Appl. No.	:	10/561,802
Filed	:	December 22, 2005
For	:	DEVELOPER COMPOSITION FOR RESISTS AND METHOD FOR FORMATION OF RESIST PATTERN
Examiner	:	Le, Hoa Van
Group Art Unit	:	1752

SUBMISSION WITH RCE**Mail Stop Amendment**

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Dear Sir:

In response to the decision mailed by the Board of Patent Appeals and Interferences mailed **March 30, 2010**, Applicants respectfully request consideration of the following amendments and remarks:

Amendments to the Claims appear in the listing of claims, which begins on page 2 of this paper.

Remarks/Arguments begin on page 3 of this paper.